



U.S. Department of State U.S. Embassy in Cairo

Between the Lines: International Writer's Program for Chaperones

Description

In cooperation with the prestigious International Writing Program (IWP) at the University of Iowa and Iowa Young Writers Studio (IYWS), the U.S. State Department's Cultural Programs Division is pleased to announce that the fourth session of Between the Lines (BTL) will take place July 10-25, 2011. Between the Lines brings young aspiring writers from Arabic-speaking countries in the Middle East and North Africa to the University of Iowa to spend two weeks honing their creative writing skills along with their American peers. Students (between the ages of 16 and 19) will be accompanied by chaperones.

More information about this program can be found here: <http://iwp.uiowa.edu/projects/BTL/index.html>

Eligibility Criteria

All chaperones must:

- Be citizens, nationals or permanent residents qualified to hold a valid Egyptian passport
- Between the ages of 25 and 40 as of July 11, 2011 and proficient in Arabic and English (reading, writing, and speaking)
- Demonstrate experience working with young people, particularly students in the demographic (secondary school/college undergrad)
- Be able and willing to expand his or her teaching strategies/expertise by attending a week-long Iowa Summer Writing Festival class (presented at the University of Iowa)
- Be willing to assist BTL faculty and IWP staff with projects related to promoting creative writing and the teaching of creative writing in the Middle East
- Aspire to a literary career and/or a teaching career involving creative writing and/or literature

Application Instructions

To download the CHAPERONE application, please visit: <http://egypt.usembassy.gov/pa/xchgs.html>

All applicants are required to submit the completed application, copy of passport or ID, and an updated CV with all supporting documents to ExchangesCairo@state.gov indicating the name of the program in the subject.

Applications submitted after the deadline will not be considered. Only shortlisted candidates will be contacted for an interview.

Deadline for Applications: March 1, 2011, 4:30 p.m.